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Prediction of Two-Dimensional Phase of Boron with Anisotropic Electric Conductivity

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Supporting Information

ABSTRACT: Two-dimensional (2D) phases of boron are rare and unique. Here we report a new 2D all-boron phase (named the π phase) that can be grown on a W(110) surface. The π phase, composed of four-membered rings and six-membered rings filled with an additional B atom, is predicted to be the most stable on this support. It is characterized by an outstanding stability upon exfoliation off of the W surface, and unusual electronic properties. The chemical bonding analysis reveals the metallic nature of this material, which can be attributed to the multicentered π-bonds. Importantly, the calculated conductivity tensor is anisotropic, showing larger conductivity in the direction of the sheet that is in-line with the conjugated π-bonds, and diminished in the direction where the π-subsystems are connected by single σ-bonds. The π-phase can be viewed as an ultrastable web of aligned conducting boron wires, possibly of interest to applications in electronic devices.

In the past decades, the outstanding geometry and electronic properties of graphene inspired a wide interest in low-dimensional structures.1,2 However, for elements right next to carbon in the Periodic Table—silicon, boron, and phosphorus—the preparation of elemental two-dimensional (2D) phases has been proven to be much more difficult.3-5 Among these elements, boron is particularly intriguing and challenging. First, the elemental allotropes of boron are dominated by the well-known and very stable B12 icosahedral clusters.6 Second, the 2D nature has been found to prevail only in small clusters of boron, governed by a mix of covalent and delocalized bonds in an undercoordinated situation.7,8 Planarity does not easily translate to extended systems, because of the electron-deficient nature of boron, as compared to carbon: like a metal, the metalloid boron tends to go toward 3D bulk. In purely theoretical works, a large amount of effort went into finding stable 2D boron phases, e.g., the α sheet,9,10 β sheet,9,10 and γ sheet11,12 by different approaches, including cluster expansion (CE),13 particle-swarm optimization (PSO),14,15 and based on existing structural characteristics.16 These works mainly focus on the boron monolayer, constraining the global optimization to two dimensions, and not considering the possibility of growing the boron phase on a substrate to support it. The substrate, however, plays a crucial role in experimental preparation of 2D boron, which is one of the major differences between boron sheets and graphene in the experiment. Only very recently have a few types of boron sheets been synthesized on Cu foils16 and on a Ag(111) surface5,17 by chemical vapor deposition (CVD). In these cases, the exoticism of boron structures again implied the complexity of the bonding features. The substrate obviously dictates the structural and electronic preferences in these materials, and also the feasibility of their preparation. Accordingly, the possibly rich 2D chemistry of boron might be accessible through templating on different supporting surfaces.

In this work we focus on the most stable surface of tungsten, W(110), as a substrate for 2D boron growth. This surface features good stability and an excellent performance in growth of carbon nanotubes.18 Most importantly, while Cu and Ag surfaces have an hexagonal symmetry, W(110) has a rectangular symmetry. Therefore, it might be a promising support to obtain novel boron monolayers. Indeed, we will describe here a unique new 2D sheet of boron that can be formed on the W(110) substrate and, upon exfoliation, retains its structure and stability up to strikingly high temperatures. We show that this phase possesses special electronic structure and anisotropic electric conductivity.

To identify the most stable structure of 2D boron on W(110), we applied the particle-swarm global optimization method19-21 combined with DFT-PBE calculations22,23 to explore several different chemical compositions, varying the...
number of B atoms from 12 to 18 per supercell, within an area of 6.34 Å × 8.97 Å. In order to estimate the relative stabilities of different compositions, we calculate the cohesive energy,

$$E_c = \frac{E_{tot} - E_{sub} - nE_B}{n}$$

(1)

where $E_{tot}$ is the total energy of the system with the boron sheet on the substrate, $E_{sub}$ is the energy of pure W substrate, $E_B$ is the energy of a single boron atom and $n$ the number of B atoms. Note that the specific product obtained in the chemical vapor deposition depends not only on the cohesive energy $E_c$, but also the condition of preparation, which determines the chemical potential of boron. The predicted global minima structures for each composition and their corresponding cohesive energies are shown in Figure 1 (see also the Figure S2 of the Supporting Information for the detailed structures with unit cell labeled).

All the structures are based on a triangular lattice, where each boron is three or four-coordinated, a common feature in boron monolayers. Due to the symmetry of the W substrate, however, these structures are quite different from the ones reported previously.5,16,17 Their most distinct feature is that they are composed of both four-membered and six-membered boron rings, where the formation of the four-membered rings can be regarded as a compromise in order to match the substrate structure as much as possible. First, boron atoms tend to form an epitaxial skeleton, matching the distribution of tungsten atoms. As the number of boron atoms increases, boron atoms fill the “holes” of the hexagons. Previous studies9,15 found that filling all of the holes is unfavorable, due to the electron-deficient nature of boron. In fact, electron-deficient bonding generally has a strong multicenter character, which would tend to favor greater aggregation of atoms and destabilize 2D boron. Our results further confirm this phenomenon by manually...
adding the boron atoms to the holes of the six-membered rings, which is found to be energetically unfavorable. Indeed, although the cohesive energy is still negative for the case where the number of boron atoms is larger than 16, its absolute value decreases significantly, indicating that the structure is unwilling to accept new boron atoms to fill the holes. Therefore, the structure containing 16 B atoms (Figure 2a), is thermodynamically more likely to be prepared in practice. To our knowledge, this structure has never been reported, and we will hereafter refer to it as π sheet.

Due to the interaction with the substrate, the π phase is slightly buckled (Figure 2b); the Bader charge analysis shows a small charge transfer from the W surface to the boron sheet. We note that the amount of charge on boron here is relatively larger than the case of other 2D boron on Cu(111) (usually smaller than 0.1 e per boron atom).24 This is due to the bigger electronegativity difference between B and W, compared to the difference between Cu and B, and reflects a stronger interaction in the present case, leading to a distinctive 2D structure. Next, we analyze the π sheet without the substrate. Alone, this monolayer is a totally flat 2D material (Figure 2c) and the phonon analysis,25 with no imaginary frequencies (see Figure S3 of the Supporting Information), confirms its dynamical stability. Additionally, ab initio MD simulations are performed at different temperatures in order to study the thermal stability of the new boron phase. These calculations suggest that the π sheet is stable up to 1800 K and only small buckling vibration, following the normal phonon mode, occurs with temperatures below 1800 K. Thus, the π sheet is a kinetically trapped, highly stable metastable polymorph. At 1800 K, the structure undergoes a phase transition and form the previously reported χ3 structure,11,12 (see Figure 2d), which is theoretically proven to be one of the most stable boron monolayer and has been prepared on a Ag(111) surface recently.7 This phase is 0.05 eV/B atom more stable than the π phase without support. Nevertheless, on the W(110) substrate, the χ3 sheet is less stable than the π sheet by ca. 0.13 eV/boron atom, due to the geometric mismatch between the χ3 sheet and the W surface. This phenomenon shows again the great influence of the substrate on the 2D boron and how the structural and electronic properties can be tailored by “playing” with the substrate.

It should be noted that with 16 boron atoms per supercell, a structure composed of only four-membered rings is also predicted (see Figure 2e). Its stability is competitive with that of the π sheet while on the substrate. However, the four-membered-ring structure without the substrate is indeed unstable: (i) its energy is higher than the energy of the π sheet by ca. 0.31 eV/atom, and (ii) it shows a large imaginary frequency of 83 cm−1, indicating dynamical instability.

Next we consider the electronic structure of the π sheet. First, we calculate the electronic band structure and the projected density of states (PDOS) (Figure 3). The band structure shows a metallic character, which is a common feature of 2D boron, despite the semiconductivity of the boron bulk. The results are similar when treating the band structure with PBE25 and the hybrid functional HSE06,27,28 especially for the states near the Fermi level. Even if spin polarized calculations were performed, the ground state of this material has no unpaired electrons, being diamagnetic. From the PDOS analysis, the valence states are mainly 2p states hybridized with 2s states of boron. The main contribution to the states around the Fermi level arises from the 2p, orbitals of B.

These features inspire us to establish a connection between the delocalized electronic band structure and the chemical bond so that one can easily understand the electronic structures of 2D boron. The chemical bonding is analyzed using the Solid State Adaptive Natural Density Partitioning (SSAdNDP) method.29 This method can be regarded as an extension of the NBO method. It maximally localizes the electron pairs into 1-center (lone-pairs), 2-centers (single bonds), and multi-centered bonds (delocalized bonds). The results are shown in Figure 4. The chemical bonding is quite similar to the elemental boron, with the formation of eight three-centered two-electron (3c-2e) σ bonds: two 3c–2e bonds on the squares and six 3c–2e on the hexagons, with high occupation numbers (ON = 1.95–1.81 lel) (Figure 4b,c). So B3 can be viewed as the basic building block of the boron network. Additionally, one 2c–2e bond (ON = 1.79 lel) plays a bridging role to connect the six-membered and the four-membered rings (Figure 4a). The σ bonds are mainly composed of the sp2 hybrid orbitals of boron, which agrees well with the 2s component peaks in the PDOS analysis. After forming the covalent skeleton by these sp2 hybrid orbitals, the remaining 2p, orbital on each boron forms delocalized π bonds. In fact, we found two types of π bonds in the π sheet: one 4c–2e (ON = 1.74 lel) and one 7c–2e bond (ON = 1.90 lel), shown in Figure 4d,e. These delocalized π bonds provide a clear picture to understand the electronic structure of the boron sheet. First, the metallic character can be understood by the delocalized bonds. Second, the 2p⊥-dominated PDOS is obviously the result of these delocalized π bonds.

Further, as an evidence of this view, we calculate the conductivity tensor by solving the Boltzmann equation with relaxation time approximation.30 It should be noted that there is still an unknown relaxation time τ in the denominator of conductivity, which is one limitation of the Boltzmann semiclassical approach. However, in this preliminary exploration of the transport properties, the relaxation time τ can be treated as a constant. Previous studies11,12 have verified the validity of this approximation and implied that even for systems with highly anisotropic crystal axes, the approximation works quite well. According to the symmetry, the conductivity tensor is diagonalized. The components along the x and y axis at 300 K, listed in Figure 4, show that the conductivity along the x direction is approximately 4 times greater than that along the y direction. This can be easily understood from the bonding.
analysis: the x direction contains a continuous distribution of delocalized π bonds, while in the y direction, the π bonds are separated by $2c\cdots2e$ σ bonds. Such continuous delocalized bond distribution leads to a significantly larger conductivity in x direction, which makes the π sheet a potential anisotropic electric material. Notably, the origin of the conduction in 2D boron sheet is quite similar to graphene, both caused by the delocalized π bonds. However, there are still two aspects of difference: (i) the π boron sheet is anisotropic in conductivity, which may lead to interesting applications, and (ii) compared with graphene, the π bonds in boron sheets are intrinsically electron-deficient, and the Fermi level can be easily modulated by doping it with electron-rich atoms. We also calculate the case with slightly more electrons (higher chemical potential), and by doing so, the conductivity indeed increases to a large extent. Interestingly, when the chemical potential is ca. 0.22 eV above the Fermi level at 300 K, the conductivity along the x direction becomes twice as the nondoped case, however, the conductivity along the y direction is almost unchanged (Figure S5).

In summary, we predict a new 2D boron phase, π phase, that can be grown on a W substrate, which is proven to be highly stable with or without the substrate, by phonon and MD simulations. The previously reported stable 2D structures of boron are not as stable as the π phase while on W, indicating that the choice of the templating substrate is critical in defining the morphology (and hence properties) of resultant 2D boron materials. The skeleton of the π monolayer is formed by localized $2c\cdots2e$, and multicentered σ bonds. Additionally, the phase features delocalized π-states of the $2p_z$-origin, which dominate the DOS near the Fermi level, and are responsible for the metallic character of the sheet. π-dominance at $E_F$ is characteristic also of graphene, which, however, is a zero band gap semiconductor. Due to the specifics of the W-templated structure, the π-states in the material exhibit conjugation in the x-direction, and lack thereof in the y-direction, resulting in anisotropic electrical conductivity. The π-phase can be viewed as a web of aligned conducting boron wires, possibly of interest to applications in electronic devices.

### COMPUTATIONAL METHODS

The global optimization is performed by using the particle-swarm optimization (PSO) algorithm as implemented in the CALYPSO code. PSO algorithm, initially inspired by the behavior of the bird flock, has been proven to be efficient in finding the global and local minima on sophisticated energy landscapes, not only for crystal structures, but also for the surface reconstructions. In order to simulate the boron sheet on the tungsten substrate, the repeated slab model is used to describe both the surface region (including the boron sheet area constructed by the PSO algorithm and the buffer area in which the atoms are allowed to relax) and the bulk region (Figure S1). We used a rather large area of the W(110) surface ($6.34 \times 8.97$ Å) to ensure the search space was large enough to include as many surface-boron structures as possible. The generated structures were optimized using the density functional theory (DFT) implemented in the Vienna ab-initio simulation package (VASP). PBE functional was used for the structural relaxation and the stability check, including the phonon spectrum through the finite displacement approach27 and the ab initio molecular dynamics (AIMD) simulations implemented in Quantum Espresso. The DFT-D3 scheme was used to account for the dispersion interactions. The screened hybrid functional HSE06 was used for the electronic band structure calculation. The conductivity tensor was calculated using the Boltzmann semi-classical method by BoltzTraP code. The chemical bonding analysis was performed by the Solid State Adaptive Natural Density Partitioning (SSAdNDP) method. More details can be found in the Supporting Information.
ASSOCIATED CONTENT

Supporting Information
The Supporting Information is available free of charge on the ACS Publications website at DOI: 10.1021/acs.jpcl.7b00275.

Full computational details, detailed structures of 2D boron on W(110), phonon spectrum, Brillouin zone path for band calculations, and dependence of conductivity on the chemical potential $\mu$ above the Fermi level (PDF)

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The authors declare no competing financial interest.

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